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Highly selective and efficient photocatalytic reduction of nitrate in water by a tandem reaction system consisting of Pt/TiO<sub>2</sub> and SnPd/Al<sub>2</sub>O<sub>3</sub>: A comparative study of the tandem reaction system with a typical semiconductor photocatalyst, SnPd/TiO<sub>2</sub>



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#### ABSTRACT

A tandem reaction system consisting of a photocatalyst (Pt/TiO<sub>2</sub>) and a nonphotocatalyst (SnPd/Al<sub>2</sub>O<sub>3</sub>) promoted the reduction of  $NO_3^-$  into gaseous products (mainly  $N_2$ ) under light irradiation ( $\lambda > 300$  nm) in the presence of glucose as a hole scavenger. Photocatalytic  $H_2$  evolution  $(2H^+ + 2e^- \rightarrow H_2)$  proceeded over Pt/TiO<sub>2</sub>, and conventional catalytic reduction of  $NO_3^-$  with  $H_2$  ( $NO_3^- + 5/2H_2 \rightarrow 1/2N_2 + 2H_2O + 1/2N_2 + 2H_2O + 1/2N_2 + 2H_2O + 1/2N_2 + 2H_2O + 1/2N_2 +$ OH<sup>-</sup>) occurred over SnPd/Al<sub>2</sub>O<sub>3</sub>. We optimized the loading amount of Pt on TiO<sub>2</sub>, the Sn/Pd ratio, the loading amount of SnPd on Al<sub>2</sub>O<sub>3</sub>, and the two catalyst dosages. The optimized tandem system gave a high reduction rate of NO<sub>3</sub> and a high selectivity for gas (94%) from the photocatalytic reduction of NO<sub>3</sub> in water. On the other hand, a typical semiconductor photocatalyst SnPd/TiO<sub>2</sub> with an optimized Sn/Pd ratio and an optimized loading amount of SnPd bimetal on TiO2 reduced NO3 about two-thirds as fast as the tandem system and was less selective for gas (70%). The tandem system suppressed the wasted H<sub>2</sub> formation, resulting in high light use efficiency for the NO<sub>3</sub> reduction (95%), which is defined as the ratio of the number of electrons consumed for NO<sub>3</sub> reduction to the total number of electrons consumed for both NO<sub>3</sub> reduction and photocatalytic H<sub>2</sub> evolution, though the tandem and SnPd/TiO<sub>2</sub> systems consumed about the same total number of electrons. The tandem system has two advantages: (i) the Pt/ TiO2 and SnPd/Al2O3 subsystems can be separately designed to give highly efficient photocatalytic and catalytic reactions, respectively; and (ii) the reaction rates of photocatalytic and catalytic reactions can be easily controlled by changing the catalyst dosage in the reactor. Those advantages brought about a high reduction rate for NO<sub>3</sub>, high selectivity for gas, and high light use efficiency for NO<sub>3</sub> reduction in the photocatalytic reduction of NO<sub>3</sub> in water.

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#### 1. Introduction

Photocatalytic reactions over semiconductor photocatalysts, such as  $TiO_2$  and  $WO_3$ , proceed sequentially by the following steps: (i) adsorption of substrate onto the surface, (ii) photoabsorption forming photoexcited electrons  $(e^-)$  and holes  $(h^+)$  in the bulk, (iii) migration of  $e^-$  and  $h^+$  to the surface, (iv) participation of  $e^-$  and  $h^+$  in reduction and oxidation, respectively, with the substrates on the surface, and (v) recombination of unreacted  $e^-$  and  $h^+$ . For reactions in aqueous solution, water is included in the substrate in steps (i) and (iv). The observed rates of the chemical reactions, that is, the rates of reactant consumption and product formation,

depend on the rates of these steps, unless radical chain reactions occur in solution or gas phase. The rates of steps (i), (ii), (iii), and (iv) positively influence the observed rate, whereas the rate of (v) negatively influences it, if those are involved in the rate-determining step.

Generally, the photocatalytic activity of unmodified (bare) semiconductor photocatalysts is low, but the rate can be dramatically increased by modifying the semiconductor with a small amount of a metal [1-29], which is called a co-catalyst. One function of co-catalysts, such as Pt [1-5] and Pd [6-10], is to prolong the charge-separated state of photoexcited electrons and holes by the trapping of either electrons or holes on the co-catalyst [11]. In this way, the rate of (v) is decreased, although an excess of the co-catalyst increases the rate of recombination of  $e^-$  and  $h^+$  [11]. Another function of co-catalysts is to activate substrate

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molecules via adsorption, which accelerates the rate of (iv): for example,  $NiO_x$  [12–16] and  $Rh_{2-v}Cr_vO_3$  [17–19] for water splitting; Ag [20-22] for  $CO_2$  reduction; and CuPd [23-26] for  $NO_3^-$  reduction. For the photocatalytic reduction of CO<sub>2</sub> or NO<sub>3</sub> in water, the photocatalytic reduction of water (H<sup>+</sup>) to form gaseous H<sub>2</sub> can occur in parallel with the target reaction over a co-catalyst with low hydrogen overpotential such as Pt or Pd [23,27,28]. Photocatalytic H<sub>2</sub> evolution lowers the photocatalytic performance for the target reaction, as pointed out by Anderson [27,28] and Lucchetti et al. [30], because photoexcited electrons are wasted to form H<sub>2</sub>, rather than reducing the substrates in water. Thus, H<sub>2</sub> production needs to be suppressed to enhance photocatalytic efficiency. Because both reactions (H<sub>2</sub> evolution and the reduction of CO<sub>2</sub> or NO<sub>3</sub>) proceed on the co-catalyst, the co-catalyst needs to have excellent adsorption of substrate molecules to preferentially promote the reduction of substrates rather than H2 evolution. If the two functions of the co-catalyst (prolonging the charge-separated state of photoexcited electrons and holes and activating substrate molecules) are maximized simultaneously by optimizing the design of the co-catalyst, including the choice of element, loading amount, crystalline structure, and particle size, then extremely highperformance semiconductor photocatalysts can be obtained. However, it is very difficult, in general, to achieve simultaneous maximization.

To overcome this difficulty, the use of a tandem reaction system has been proposed, in which the photocatalytic/catalytic functions are distributed to separate particles and these are reconstituted in the reaction mixture. Artificial Z-scheme photocatalytic water splitting [31–33], which affords  $H_2$  and  $O_2$ , is a great example of function distribution over separate catalysts. In the Z-scheme photocatalytic system,  $O_2$  and  $H_2$  evolution sites are built on separate semiconductor photocatalysts (e.g.,  $WO_3$  for  $O_2$  evolution and TaON for  $H_2$  evolution), and the two catalysts are added to the reaction mixture with a redox shuttle between them.

We have previously reported a tandem reaction system consisting of a photocatalyst and a nonphotocatalyst (typical catalyst) for the photocatalytic reduction of  $NO_3^-$  in water (Fig. 1a) [34–36]. In the tandem reaction system,  $H_2$  is formed by a photocatalytic reaction over the photocatalyst,

$$2H^+ + 2e^- \rightarrow H_2, \tag{1}$$

and this H<sub>2</sub> reduces NO<sub>3</sub> in water over the nonphotocatalyst:

$$NO_3^- + 5/2H_2 \rightarrow 1/2N_2 + 2H_2O + OH^-.$$
 (2)

In the tandem reaction system, the photocatalyst and nonphotocatalyst can be developed independently to maximize their performance. In addition, the two reaction rates can be adjusted appropriately by changing the doses of the photocatalyst and nonphotocatalyst in the reaction mixture. Thus, the tandem reaction system has a great potential to become a much better system for photocatalytic  $NO_3^-$  reduction in terms of both activity and selec-

tivity than a conventional system of a semiconductor directly combined with a co-catalyst, which we call a single reaction system (Fig. 1b). Based on the concept described above, we have developed a tandem reaction system using a photocatalyst (Pt/TiO<sub>2</sub> [34,35], Pt/SrTiO<sub>3</sub>:Rh [36]) and a nonphotocatalyst (SnPd/Al<sub>2</sub>O<sub>3</sub>) that shows high photocatalytic activity and excellent selectivity for gases, including  $N_2$  and  $N_2$ O.

In the present study, we compared in detail the photocatalytic performance of a tandem reaction system consisting of a  $Pt/TiO_2$  photocatalyst and a  $SnPd/Al_2O_3$  nonphotocatalyst with that of a single semiconductor photocatalyst,  $SnPd/TiO_2$ , to demonstrate the superiority of the tandem reaction system. Before the comparison, the tandem and single reaction systems were comprehensively optimized. In particular, we focused on the reduction rate of  $NO_3^-$ , product selectivity, and light use efficiency for  $NO_3^-$  reduction. The photocatalytic reduction of  $NO_3^-$  in water is a promising method of purifying groundwater polluted with  $NO_3^-$ , which is a serious global problem. In the purification of groundwater, the formation of ammonia and ammonium ions is undesirable due to their toxicity, and so the reaction systems should have high selectivity for gaseous products, such as  $N_2$  and  $N_2O$ , as well as high photocatalytic activity.

#### 2. Experimental

#### 2.1. Preparation of catalysts

Aeroxide TiO<sub>2</sub> P25 (Evonik) was used as a TiO<sub>2</sub> photocatalyst. Modification of TiO<sub>2</sub> with Pt was conducted by photodeposition. TiO<sub>2</sub> (2 g) was dispersed in distilled water (135 cm³) and then CH<sub>3</sub>-OH (15 cm³, Wako Pure Chemical Industries) and H<sub>2</sub>PtCl<sub>6</sub>·6H<sub>2</sub>O (0.04 mol dm $^{-3}$ , Wako Pure Chemical Industries) were added to the suspension. In a Pyrex glass cell, the suspension was sparged with a stream of N<sub>2</sub> (15 cm³ min $^{-1}$ ) for 30 min and then irradiated using a 300 W Xe lamp (Optical Modulex, USHIO) for 3 h with stirring.

The suspension was centrifuged and the supernatant was replaced with distilled water (200 cm<sup>3</sup>). The suspension was stirred for a few minutes and centrifuged again. This process was repeated three times. Finally, the catalyst powder was dried in air at 333 K overnight. The obtained catalyst is denoted as Pt/TiO<sub>2</sub>.

Supporting Sn and Pd on  $Al_2O_3$  (Aerosil Alu C) was conducted by incipient wetness impregnation.  $Al_2O_3$  was heated in air at 523 K for 4 h before use. An aqueous solution of PdCl<sub>2</sub> (0.112 mol dm<sup>-3</sup>, Wako Pure Chemical Industries) was dropped onto  $Al_2O_3$  (2.0 g), and the resulting wet solid was dried in air at 373 K overnight, followed by calcination in air at 523 K for 3 h. An aqueous solution of  $SnCl_2 \cdot 2H_2O$  (0.172 mol dm<sup>-3</sup>, Wako Pure Chemical Industries) was dropped onto the resulting solid, and then the wet solid was dried in air at 373 K overnight, followed by calcination in air at 523 K for 3 h. The obtained catalyst is denoted as  $SnPd/Al_2O_3$ . When we pay

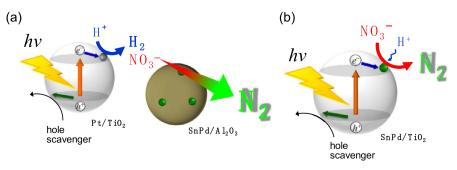


Fig. 1. Schematic images of (a) a tandem reaction system and (b) a single reaction system.

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